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(54) **DISPLACEMENT SENSOR WITH EMBEDDED COHERENT ELECTROMAGNETIC RADIATION INTERFEROMETER FOR MICRO SCALE PROXIMITY MEASUREMENTS**

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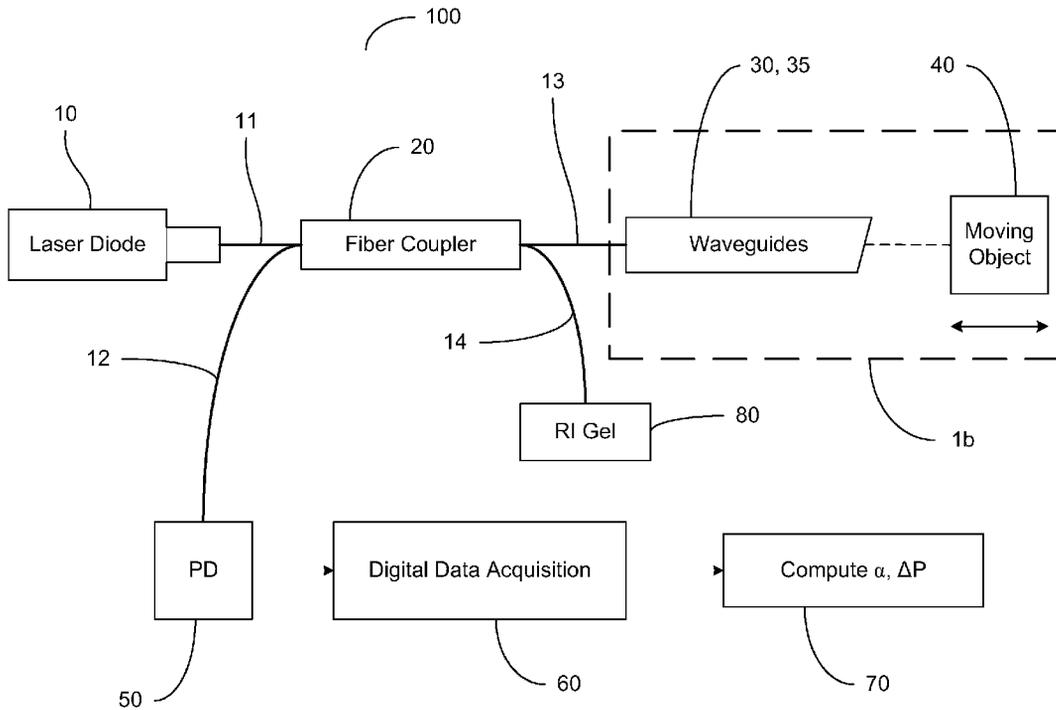
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(57) **ABSTRACT**

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The present invention is an interferometer sensor which uses frequency modulated coherent electromagnetic radiation to noncontact measure the displacement of moving targets with high precision. The sensor has an embedded interferometer comprised of an electromagnetic radiation source, a plurality of electromagnetic waveguides, interferometric and extension waveguides, a refractive index gel, or angled end face and an electromagnetic radiation detector.

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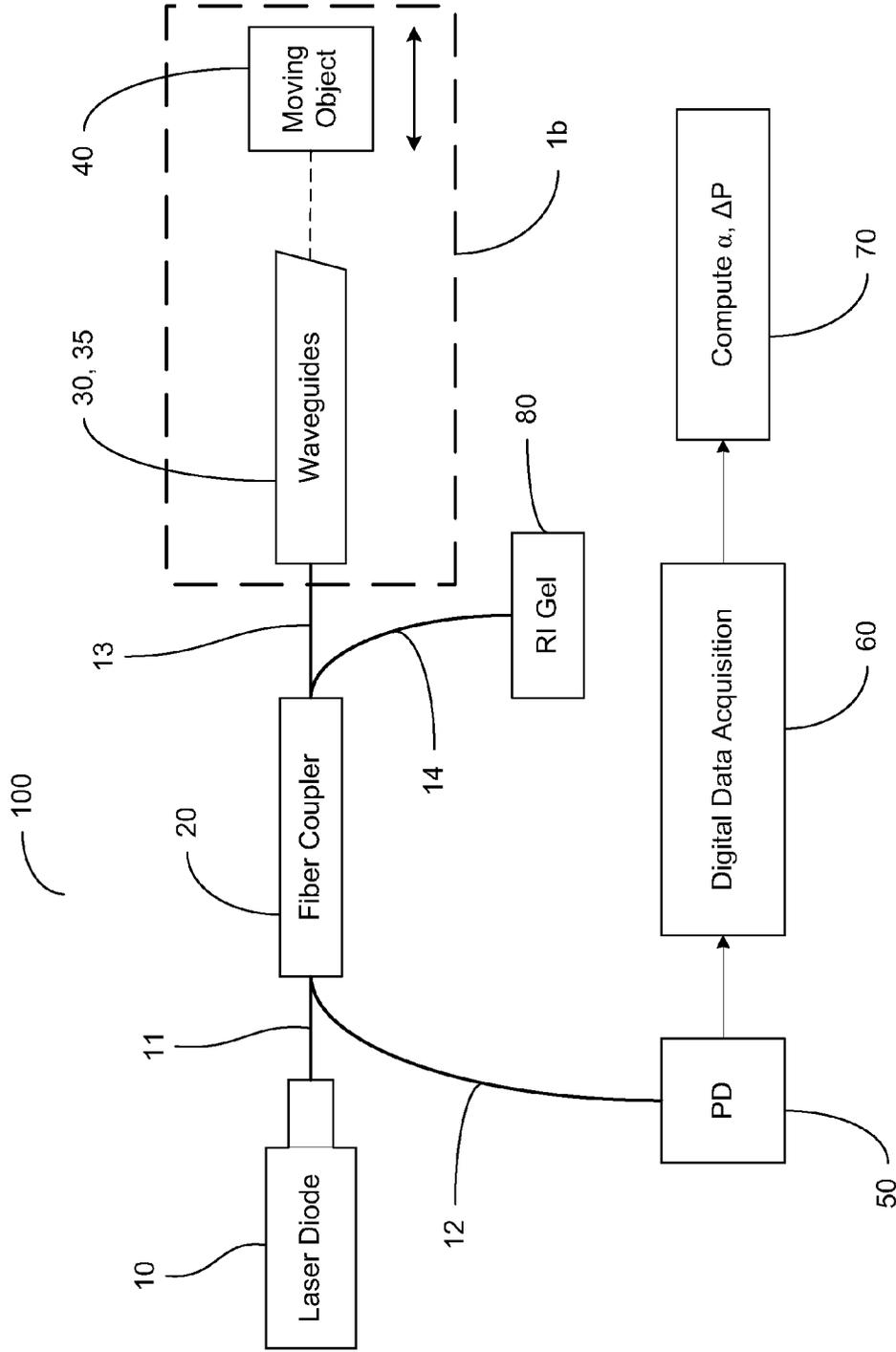


Figure 1a

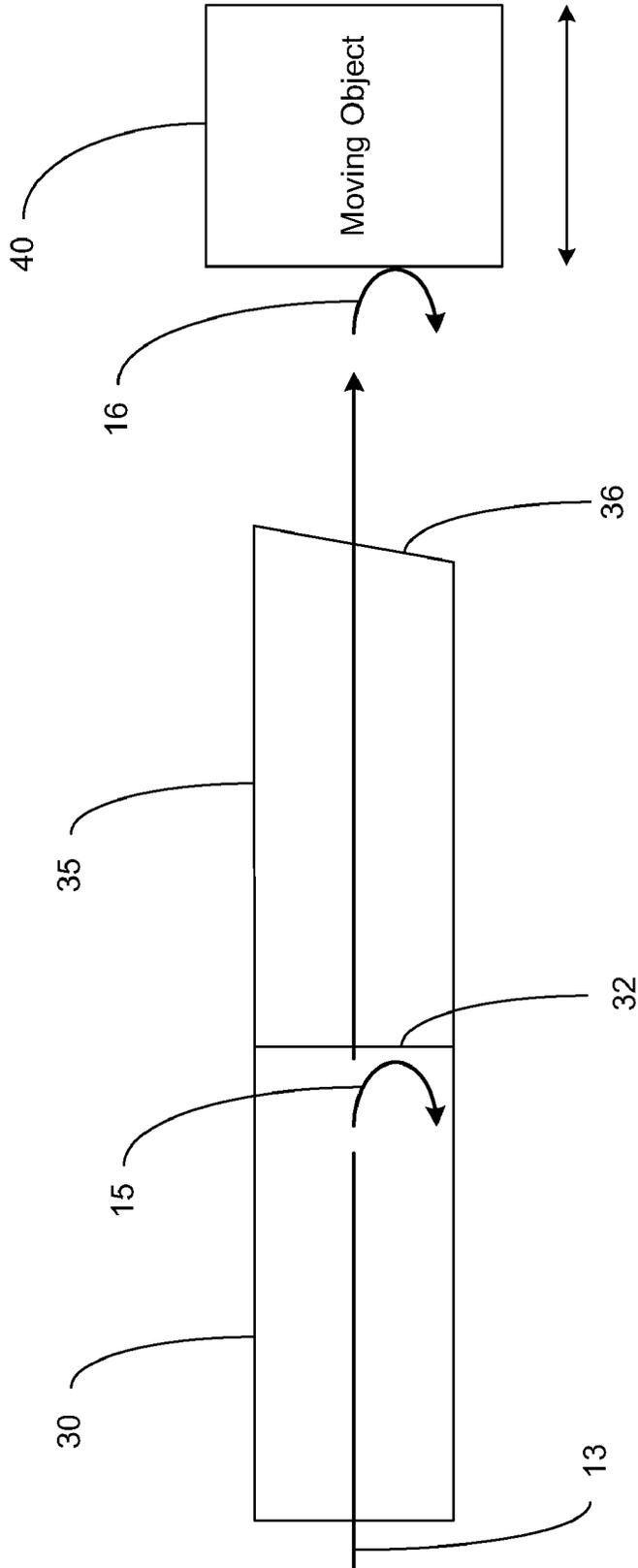


Figure 1b

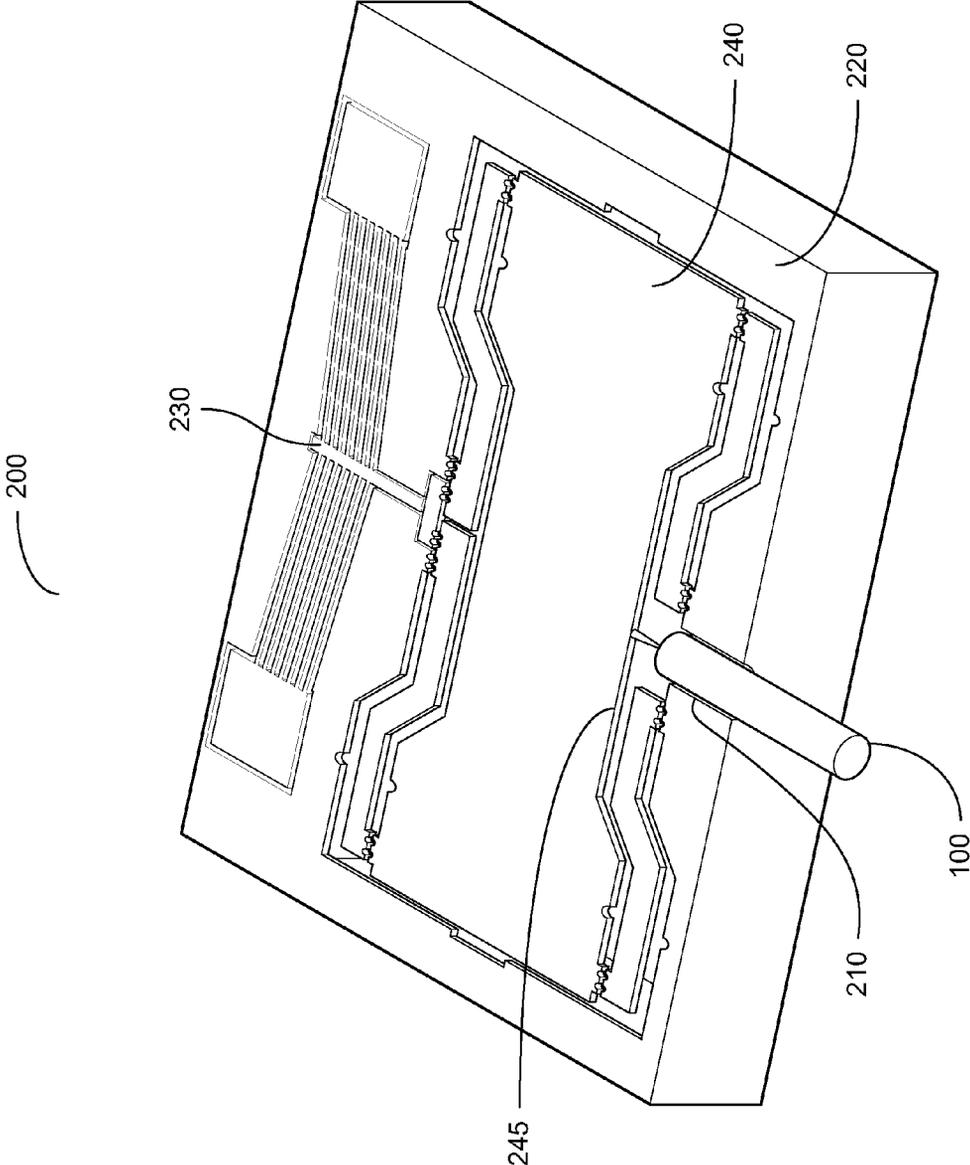


Figure 2

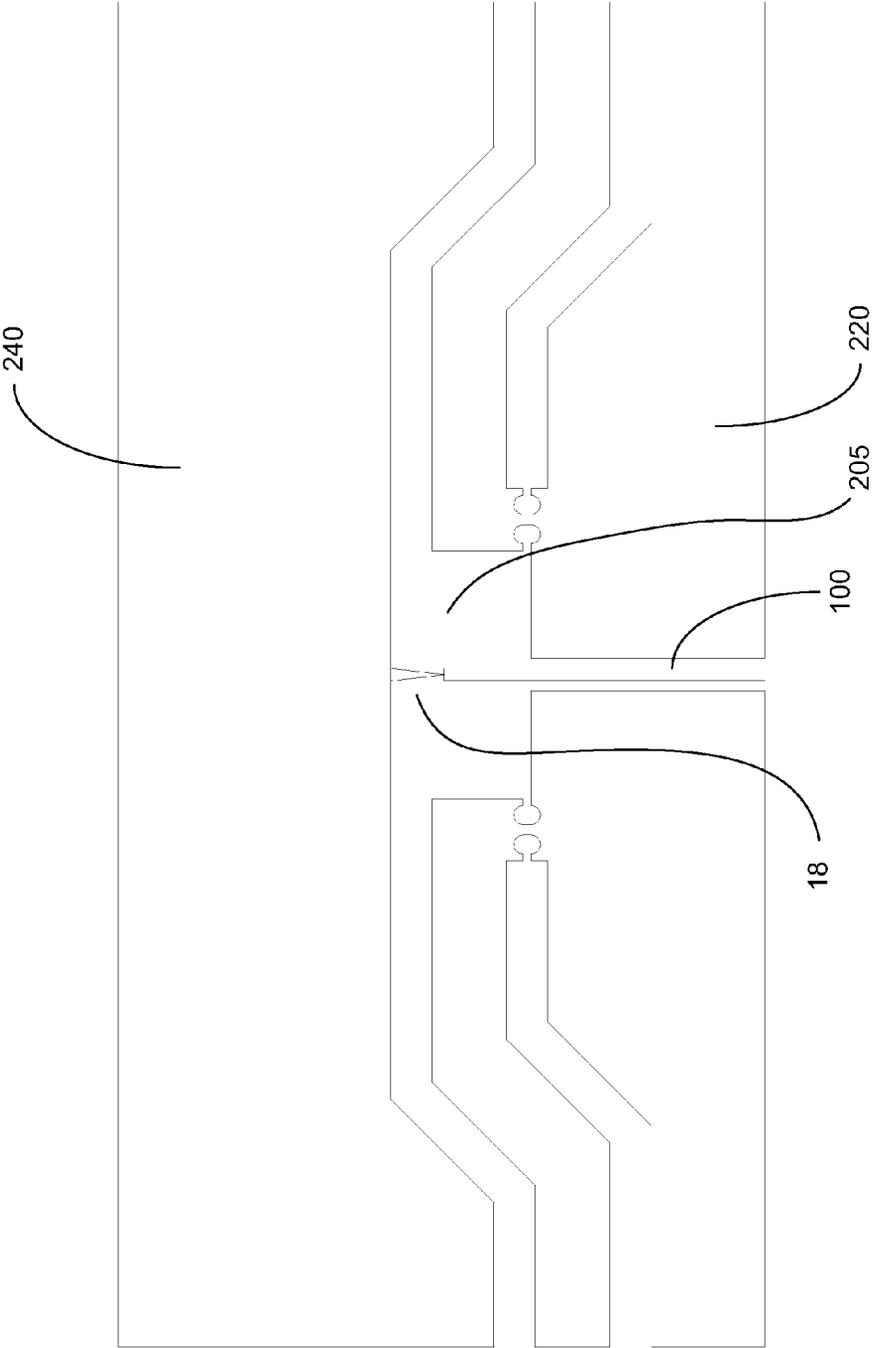


Figure 3

**DISPLACEMENT SENSOR WITH EMBEDDED
COHERENT ELECTROMAGNETIC
RADIATION INTERFEROMETER FOR
MICRO SCALE PROXIMITY
MEASUREMENTS**

STATEMENT OF FEDERALLY SPONSORED
RESEARCH

[0001] The invention described herein was made by employees of the United States Government and may be manufactured and used by or for the Government of the United States of America for governmental purposes without the payment of any royalties thereon or therefor.

FIELD OF INVENTION

[0002] The present invention relates to the field of interferometry and more particularly to a displacement sensor with an embedded coherent electromagnetic radiation interferometer.

BRIEF DESCRIPTION OF THE DRAWINGS

[0003] FIG. 1a illustrates a schematic of an exemplary embodiment of a displacement sensor with embedded coherent electromagnetic radiation interferometer for micro scale proximity measurements.

[0004] FIG. 1b illustrates a close-up view of area 1b of FIG. 1a.

[0005] FIG. 2 illustrates a perspective view of an exemplary embodiment of a planar nanopositioner fitted with single mode optical fiber waveguide.

[0006] FIG. 3 illustrates a close-up view of the end face of an optical fiber when visible electromagnetic laser radiation is injected through the optical fiber.

GLOSSARY

[0007] As used herein, the term “non-stationary target” refers to an object that does not have a fixed position.

[0008] As used herein, the term “refractive index gel” refers to a material that has a refractive index and dispersion to coherent electromagnetic radiation that closely matches the refractive index and dispersion of the interferometer waveguide for the same electromagnetic radiation.

BACKGROUND

[0009] The tremendous growth of opto-electronic device manufacturing has raised the need for high performance micro and nanopositioners, which are used in assembly and alignment. The static and dynamic performance of micro and nanopositioners depends in part on the quality of operation of their controllers, which in turn depends to a significant degree on the accuracy of the kinematic and dynamic mathematical models upon which they are based.

[0010] The utilization of microelectromechanical systems (MEMS) for nanotechnology research and nanomanufacturing has a number of critical applications. The combination of MEMS and nanotechnology, however, presents a number of new challenges not experienced in more common MEMS applications in sensors and telecommunications. Most importantly, precision motion control of MEMS actuators is critical as resolution, accuracy, and repeatability are expected to be on the order of nanometers.

[0011] Nanopositioners equipped with nanoprobes are devices that can precisely manipulate nano-scale objects. The sizes of the nanopositioners used for this work are a few hundreds of micrometers. Motion range is 25 μm to 50 μm and desired step resolution is a few nm. The nm resolution opens the possibility to control nano-objects, such as nano wires and biological or chemical building blocks. These requirements constrain motion control law specifications in terms of the system precision and dynamic performance. A displacement sensor is a critical component in controlling the motion of a nanopositioner.

[0012] Displacement sensors, which are known in the art, can be embedded into the devices along the axes of the actuators, eliminating Abbe sine displacement measurement error and improving the accuracy capability of the nanopositioner. Designing a displacement sensor that can be embedded in a MEMS device is extremely difficult due to the small size of the devices, which typically have an external dimension of 1 mm to 3 mm and are made of a single crystal of silicon.

[0013] One example of a displacement sensor is disclosed by Osami Sasaki and Takamasa Suzuki in *Interferometric Displacement Sensors Using Sinusoidal Phase-Modulation and Optical Fibers* (Advanced Materials and Devices for Sensing and Imaging II, Proceeding of SPIE, Vol. 5633 (2005)) (hereinafter Sasaki et al.). The displacement sensor disclosed by Sasaki et al. generates coherent electromagnetic radiation using a laser diode coupled to an optical fiber through an optical isolator and lens. The injection current to the diode is modulated with a sinusoidal signal of controlled amplitude. The electromagnetic radiation is distributed to two optical fibers using a coupler. A portion of the electromagnetic radiation traveling through the first optical fiber is reflected by the end face of that fiber and forms the interferometer reference signal, which travels back through the optical fiber and falls on a photodetector. Another portion of the electromagnetic radiation traveling through the first optical fiber is reflected by the object (target) surface and propagates back through the optical fiber and falls on the photodetector. The photodetector detects the interference signal of the two waveforms.

[0014] The electromagnetic radiation traveling through the second optical fiber is directed to a photodiode that detects the intensity of the laser diode signal.

[0015] In addition, the Sasaki et al. technique requires that a feedback controller be used in order to maintain the amplitude of the laser diode current $a=(\lambda_0^2/4\beta P)$, where P is the distance between the end face of the first optical fiber and the object (target) reflecting surface, λ_0 is the mean value of the modulated electromagnetic radiation wavelength, β is the modulation efficiency of the electromagnetic radiation source. If that condition is satisfied, the distance P is given by $P=\alpha(\lambda_0/4\pi)$, where α is an angle determined by data obtained from the interferometric signal.

[0016] The amplitude of the laser diode current makes the Sasaki et al. technique impractical for use in MEMS devices. Due to the size of the MEMS devices, the interferometric sensor distance P ranges from a few micrometers to 150 μm . For a typical value of $\beta=0.0171$ nm/mA, the required current amplitude for a $\lambda_0=1550$ nm is $a=234.16$ mA, which is a high power requirement that is impractical.

[0017] It is desirable to have a displacement sensor that requires a low voltage and power supply.

[0018] It is desirable to have a displacement sensor which is on a micro/nano scale size and is capable of being embedded

in a microchip device to integrate the electromagnetic radiation source and the controller electronics in the device.

[0019] It is desirable to have a displacement sensor that can be interfaced with macro scale components.

[0020] It is desirable to have a displacement sensor that has range of up to a few millimeters, target proximity from a few micrometers to 0 micrometers, and accuracy, repeatability and resolution of a few nanometers.

[0021] It is desirable to have a displacement sensor that is non contact and has no moving components.

[0022] It is desirable to have a displacement sensor that is inexpensive to manufacture.

SUMMARY OF THE INVENTION

[0023] The present invention is an interferometer sensor which uses frequency modulated coherent electromagnetic radiation to noncontact measure the displacement of non-stationary targets with high precision. The sensor has an embedded interferometer comprised of an electromagnetic radiation source, a plurality of waveguides, interferometric and extension waveguides, a refractive index gel, and an electromagnetic radiation detector. The distance of the waveguide embedded interferometer from the extension waveguide end face, measured along the waveguide centerline, should not exceed $\lambda_0^2/4\beta a$, where λ_0 is the mean value of the modulated electromagnetic radiation wavelength, β is the modulation efficiency of the electromagnetic radiation source, and a is the amplitude of the modulation signal.

[0024] In an exemplary embodiment, the end face of the extension waveguide is angled, which minimizes the electromagnetic radiation back reflection along the centerline of the waveguide. The distance between the waveguide end face and the target surface can range from a few micrometers to 0 micrometers. During operation, the value of a should be controlled so that $\epsilon = (\lambda_0^2/4\beta a) - L_w$, where ϵ is the distance between the end tip of the waveguide and the target and L_w is the distance of the waveguide embedded interferometer from the waveguide end face, both measured along the waveguide centerline. The target surface should be sufficiently reflective in order to generate a detectable interferometric signal.

DETAILED DESCRIPTION OF INVENTION

[0025] For the purpose of promoting an understanding of the present invention, references are made in the text to exemplary embodiments of a displacement sensor with embedded coherent electromagnetic radiation interferometer for micro scale proximity measurements, only some of which are described herein. It should be understood that no limitations on the scope of the invention are intended by describing these exemplary embodiments. One of ordinary skill in the art will readily appreciate that alternate but functionally equivalent components, materials, and placement may be used. The inclusion of additional elements may be deemed readily apparent and obvious to one of ordinary skill in the art. Specific elements disclosed herein are not to be interpreted as limiting, but rather as a basis for the claims and as a representative basis for teaching one of ordinary skill in the art to employ the present invention.

[0026] It should be understood that the drawings are not necessarily to scale; instead, emphasis has been placed upon illustrating the principles of the invention. In addition, in the

embodiments depicted herein, like reference numerals in the various drawings refer to identical or near identical structural elements.

[0027] Moreover, the terms “substantially” or “approximately” as used herein may be applied to modify any quantitative representation that could permissibly vary without resulting in a change in the basic function to which it is related.

[0028] FIG. 1a illustrates an exemplary embodiment of displacement sensor 100 with embedded coherent electromagnetic radiation interferometer for micro scale proximity measurements. Displacement sensor 100 is comprised of laser diode 10, fiber coupler 20, interferometric waveguide 30, extension waveguide 35, photodetector 50, refractive index gel 80, signal processor 60 for digital data acquisition, and computer 70 for calculating α and ΔP . Laser diode 10 generates electromagnetic radiation that travels through first optical fiber 11 into fiber coupler 20. Fiber coupler 20 distributes electromagnetic radiation through optical fibers 13, 14. The portion of the electromagnetic radiation traveling through optical fiber 14 passes through optical object 80 and into refractive index gel contained in object 80. The gel absorbs the electromagnetic radiation and prevents any back reflection through fiber 14. Any functionally equivalent means that absorbs the electromagnetic radiation and prevents any back reflection is acceptable. For example, the gel or an angled waveguide end face could also serve the same purpose.

[0029] A second portion of the electromagnetic radiation traveling through optical fiber 13 passes through interferometric waveguide 30 with embedded extension waveguide 35. Interface 32 between interferometric waveguide 30 and embedded extension waveguide 35 forms a back reflecting discontinuity that generates electromagnetic radiation reference beam 15 (see FIG. 1b).

[0030] After passing interferometric waveguide 30 and extension waveguide 35, the electromagnetic radiation beam reflects off moving object 40 generating moving target electromagnetic radiation beam 16 (see FIG. 1b). Moving target electromagnetic radiation beam 16 propagates back through extension waveguide 35, interferometric waveguide 30, and fiber coupler 20. Moving target electromagnetic radiation beam 16 then passes through optical fiber 12 and falls on photodetector 50.

[0031] Photodetector 50 detects the interference signal of electromagnetic radiation reference beam 15 and target electromagnetic radiation beam 16.

[0032] In the embodiment shown, extension waveguide 35 has an angled end face 36 which prevents a second electromagnetic radiation beam from being generated. The waveguide end face angle has an optimum value, which ranges from 5° to 15° for a $\lambda_0=1550$ nm. Antireflecting coating of the waveguide end face can also have a beneficial effect in preventing a radiation back reflection. The distance between the waveguide end face and the target surface can be a minimum of zero to a few micrometers. During operation, the value of a should be controlled so that $\epsilon = (\lambda_0^2/4\beta a) - L_w$, where ϵ is the distance between the end tip of the waveguide and the target and L_w is the distance of the waveguide embedded interferometer from the waveguide end face, both measured along the waveguide centerline. The target surface should be sufficiently reflective in order to generate a detectable interferometric signal.

[0033] In an exemplary embodiment, an extension waveguide **35** was added to the interferometric waveguide **30** with a length L_w which does not exceed $(\lambda_0^2/4\beta a)$, where λ_0 is the mean value of the modulated electromagnetic radiation wavelength, β is the modulation efficiency of the electromagnetic radiation source, and a is the amplitude of the modulation signal. With the addition of the extension waveguide **35**, P now equals $L_w + \epsilon$, where L_w is the length of the extension waveguide **35** and ϵ is the distance between the extension waveguide **35** end face and moving object **40**. Since now $P = L_w + \epsilon$ it is easy to meet the Sasaki condition with a relatively low power coherent electromagnetic radiation source. In an exemplary embodiment, the current amplitude can be maintained by a laser diode with an embedded optical isolator and lens. Any source of coherent electromagnetic radiation known in the art, which allows frequency modulation, may also be used.

[0034] FIG. 1*b* illustrates a close-up view of interferometric waveguide **30**, interface **32**, extension waveguide **35** having angled face **36**, and moving target **40**. Also visible are optical fiber **13**, electromagnetic radiation reference beam **15**, and moving target electromagnetic radiation beam **16**.

[0035] In an exemplary embodiment, the coherent electromagnetic radiation source (e.g., laser diode **10**) is located on the device microchip; however, in other embodiments, the electromagnetic radiation source is not located on the microchip, but rather may be interfaced with the microchip using a flexible waveguide (e.g., an optical fiber) or a funnel waveguide interface. For example, the front face of extension waveguide **35** could be shaped as a funnel that will collect and focus the radiation produced by the electromagnetic radiation source. In addition, this macro-to-micro scale interface could serve as the waveguide interferometer discontinuity.

[0036] FIG. 2 illustrates a perspective view of an exemplary embodiment of planar nanopositioner **200** fitted with single mode optical fiber waveguide **100** (e.g., end portion of **35** in FIG. 1*b*). In the embodiment shown, trench **210** has been etched on nanopositioner supporting frame **220**. The opening of trench **210** has a size equal to the diameter of optical fiber **100** of the displacement sensor. The centerline of trench **210** is aligned with the centerline of nanopositioner actuator **230**.

[0037] In the embodiment shown, when displacement sensor is in position, the end face of optical fiber **100** is pointing to back face **245** of nanopositioner moving stage **240** at an approximately 100 μm distance.

[0038] FIG. 3 illustrates a close-up view of the end face of optical fiber **100** when visible electromagnetic laser radiation is injected through waveguides **13**, **30** (not shown) and optical fiber **35**. In the embodiment shown, electromagnetic radiation beam **18** is illuminating back face **245** of moving stage **240**.

[0039] In the embodiment shown, nanopositioner **200** is fabricated from a single crystal of silicon. Slot **205**, which separates moving stage **240** from supporting frame **220** is cut using a Deep Reactive Ion Etching process, resulting in a smooth surface that reflects electromagnetic radiation in the range of 600 nm to 1600 nm.

[0040] In the embodiment shown, electromagnetic radiation beam **18** ranges from 1 mW to 2 mW. A low power beam in this range results in a strong interferometric signal.

[0041] In various embodiments, the distance between end face **36** and the moving target may be varied. In an exemplary embodiment, end face **36** of waveguide **35** is placed as close as possible to the moving target (e.g., back face **245** of moving stage **240**), as long as it is not interfering with the motion of

the moving target. Since most coherent electromagnetic radiation beams have a certain amount of divergence, placing end face **36** in close proximity to the moving target allows for the maximum amount of electromagnetic radiation reflected from the target surface to reach end face **36**.

[0042] In various other embodiments, displacement sensor **100** may be designed so that extension waveguide **35** protrudes from displacement sensor **100** in order to bring it closer to the moving target. A protruding waveguide design may be designed in order not to interfere with the motion of the stage and its supporting lever mechanisms, at its maximum range of motion.

[0043] A performance test was designed to determine the accuracy of displacement sensor **100** in reproducing the motion profile of nanopositioner moving stage **240**. Standard step height artifacts were positioned and first checked with a white light interferometer for height accuracy and then were translated underneath end face **36** of extension waveguide **35** of displacement sensor **100**. Several tests were performed and two straight lines were fitted to the sensor output data, one for each scanned surface. The distance between the two lines was measured and compared with the measured step height. The average accuracy error and standard deviation were then calculated. In one embodiment, for a step having a height of 91.3 nm, the average error and standard deviation were calculated to be 5.587 nm and 2.023 nm, respectively. Displacement may be measured as photons are reflected back and enter through face **36** and generate a strong interferometric signal. The maximum distance depends on the power of the coherent electromagnetic wave, the beam divergence angle and the reflectivity of the moving target surface. Adding a focusing lens and/or increasing the beam power may extend the measurable range.

[0044] Using the performance test, it was determined that end face **36** of extension waveguide **35** has an optimum angle, with respect to the waveguide centerline, of approximately 8° and approximately 6° with antireflection coating for a $\lambda_0 = 1550$ nm. Another important finding was that the intensity of the signal passing through optical fiber **14** (non interferometric signal) does not change much and can be ignored, eliminating an intensity compensation division from the feedback control algorithm and saving control loop cycling time. This signal is replaced by a sinusoid fitted on the interferometric signal data in order to determine the values of key algorithmic data. Further simplification of the controller algorithm is also possible with the realization that the value of the control loop feedback does not change significantly during normal operating conditions. This allows the setting of the value of a (laser diode **10** modulation current amplitude) at the beginning of an operation and then continuing with open loop controller operation, resulting in an increase in the controller cycling frequency by a factor of 10, which is critical for high speed nanopositioner motions. Cycling frequency is the inverse of the time it takes to measure the photodetector **50** signal, solve the displacement problem to determine P and then calculate a using the formula $(a = (\lambda_0^2/4\beta P))$. Generally this time is a few mille seconds. The value of a may be calculated from $a = (\lambda_0^2/4\beta P)$, or after running the feedback control loop for a short time and then switching to open loop operation. In the embodiment shown, the signal generated by photodetector **50** is used in order to maintain the proper modulation current amplitude of the laser diode **10**.

What is claimed is:

- 1. A displacement sensor apparatus for measuring the displacement of a non-stationary target comprised of:
 - a coherent electromagnetic radiation source, said electromagnetic radiation source produces an electromagnetic radiation beam;
 - a plurality of electromagnetic waveguides;
 - a waveguide coupler;
 - a first waveguide;
 - a second waveguide having an end face;
 - an electro-magnetic radiation absorption component; and
 - an electromagnetic radiation detector.
- 2. The apparatus of claim 1 wherein said electromagnetic radiation absorption component is a refractive index gel.
- 3. The apparatus of claim 1 wherein said electromagnetic radiation absorption component includes an angled end face.
- 4. The apparatus of claim 1 wherein said electromagnetic radiation source is a laser diode.
- 5. The apparatus of claim 1 wherein said end face is angled within a range of 5° to 15°.
- 6. The apparatus of claim 1 wherein said electromagnetic radiation beam travels through said first waveguide and said second waveguide and reflects off of a moving target generating a moving target electromagnetic radiation beam.
- 7. The apparatus of claim 1 which further includes an interface between said first waveguide and said second waveguide that generates an electromagnetic radiation reference beam.
- 8. The apparatus of claim 1 wherein said electromagnetic radiation detector detects interference between said moving target electromagnetic radiation beam and said electromagnetic radiation reference beam.
- 9. The apparatus of claim 1 wherein said second waveguide has a length L_w which does not exceed $(\lambda_0^2/4\beta a)$, where λ_0 is a mean value of a modulated electromagnetic radiation wavelength, β is a modulation efficiency of said electromagnetic radiation source, and a is an amplitude of a modulation signal.
- 10. The apparatus of claim 1 wherein said electromagnetic radiation source is located on a device microchip.
- 11. The apparatus of claim 1 wherein said electromagnetic radiation source is interfaced with a microchip using a flexible waveguide.
- 12. The apparatus of claim 1 wherein said electromagnetic radiation source is interfaced with a microchip using a funnel waveguide interface.
- 13. The apparatus of claim 1 wherein said electromagnetic radiation beam has a power of a few mW.

- 14. The apparatus of claim 1 wherein said non-stationary target is a non-stationary stage of a nanopositioner.
- 15. The apparatus of claim 14 wherein said displacement sensor is positioned so said second waveguide lines up with the centerline of an actuator of said nanopositioner.
- 16. A microelectromechanical system having precision motion control comprised of:
 - an embedded displacement sensor for measuring the displacement of a non-stationary target comprised of:
 - a coherent electromagnetic radiation source, said electromagnetic radiation source produces an electromagnetic radiation beam;
 - a plurality of electromagnetic waveguides;
 - a waveguide coupler;
 - a first waveguide;
 - a second waveguide having an end face;
 - a refractive index gel or angled end face; and
 - an electromagnetic radiation detector; and
 - a nanopositioner comprised of:
 - a supporting frame having a trench,
 - a non-stationary stage;
 - a slot which separates said supporting frame from said non-stationary stage; and
 - an actuator, said actuator is aligned with said trench;
- wherein said embedded displacement sensor is placed in said trench and positioned so that said end face of said second waveguide is pointing at said non-stationary stage.
- 17. The system of claim 16 where said electromagnetic radiation beam travels through said first waveguide and said second waveguide and reflects off of said non-stationary stage.
- 18. The system of claim 16 wherein said end face is angled.
- 19. The system of claim 16 wherein said end face is 0 to several μm from said non-stationary stage.
- 20. The system of claim 16 wherein said nanopositioner is fabricated from silicon crystal or other materials.
- 21. The system of claim 16 wherein said non-stationary stage reflects electromagnetic radiation used by the sensor.
- 22. The system of claim 16 wherein said electromagnetic radiation has a power range of a few mW.

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